Carrier relaxation mechanisms in self-assembled (In,Ga)As/GaAs quantum dots: Efficient $P \rightarrow S$ Auger relaxation of electrons

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We calculate the *P*-shell-to-*S*-shell decay lifetime $\tau(P \rightarrow S)$ of electrons in lens-shaped self-assembled (In,Ga)As/GaAs dots due to Auger electron-hole scattering within an atomistic pseudopotential-based approach. We find that this relaxation mechanism leads to fast decay of $\tau(P \rightarrow S) \sim 1-7$ ps for dots of different sizes. Our calculated Auger-type *P*-shell-to-*S*-shell decay lifetimes $\tau(P \rightarrow S)$ compare well to data in (In,Ga)As/GaAs dots, showing that as long as both electrons and holes are present there is no need for an alternative polaron mechanism.

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I. INTRODUCTION

After photoexcitation of an electron and hole in the barrier of an (In,Ga)As/GaAs self-assembled quantum dot, the carriers relax to their ground states through a complicated dynamics. Much debate has taken place on the mechanisms responsible for the final stages of the nonradiative decay dynamics, which have been observed to involve relaxations of about 40-60 meV and take place surprisingly fast-within 2-60 ps. These decay times are much smaller than the radiative recombination times $\tau_R \sim 1$ ns observed in (In,Ga)As/GaAs dots.¹⁻³ To explain this fast relaxation, three alternative mechanisms have been proposed and supported by model calculations: multiphonon-emission, Auger carrier-carrier scattering, and polaron decay. To provide a general perspective we first outline in this paper the general decay channels of photoexcited carriers in the GaAs-barrier of (In,Ga)As/GaAs self-assembled quantum dots (Sec. II), and then focus on the $P \rightarrow S$ Auger cooling due to electronhole scattering, providing accurately calculated results. We use a realistic atomistic, pseudopotential-based approach (Sec. IV) that has been recently applied to successfully reproduce the magnitude of the radiative recombination lifetime of ground-state electrons and holes in (In,Ga)As/GaAs dots⁴ and CdSe colloidal dots.⁵ Our results for intershell decay time $\tau(P \rightarrow S)$ compare well to data from experiments in which photoexcited holes are present. Thus, as long as both an electron and hole are present, the Auger mechanism can explain fast intershell relaxation without resorting to other (e.g., polaronic decay or multiphonon emission) mechanisms.

II. CHARACTERISTIC DYNAMICAL PROCESSES OF EXCITED ELECTRONS AND HOLES IN SELF-ASSEMBLED (In,Ga)As/GaAs QUANTUM DOTS

One distinguishes first between systems having a lone carrier, either electron or hole, and systems having both an electron and hole. A lone carrier can be produced by doping the dot^{6–11} or by electrochemical injection.¹² Exciting a lone carrier and following its decay^{9–11} is a specialized field and will be reviewed briefly in Sec. II C. More commonly, we encounter relaxation of systems having both photoexcited electrons and holes. This is reviewed next. Figure 1 sketches four nonradiative relaxation processes that take place following photocreation of an electron-hole pair in an (In,Ga)As/GaAs quantum dot system. The electron is shown as a solid dot and the hole as a circle. The processes are illustrated with a dot with sparse confined electron (CB) states $\{e_0, e_1, e_2\}$, and with a much denser set of confined hole (VB) states $\{h_0, h_1, \ldots, h_k, \ldots, h_N\}$ as is characteristic of self-assembled dots. The continuum of states of the wetting layer (dashed region) and GaAs barrier (shaded) are also shown schematically. The main observed carrier relaxation processes are the following.

A. Barrier-to-wetting layer carrier capture

Nonresonant photoexcitation of an electron-hole pair in the barrier [Fig. 1(a)] often leads to capture by wetting-layer (WL) quasi-continua. This process consists of carrier thermalization within the GaAs barrier and subsequent capture by the WL. Barrier thermalization occurs within 1 ps.^{13,14} Siegert *et al.* measured time-resolved photoluminescence (PL) signal from the wetting layer of InAs/GaAs dots at high excitation and found a capture time of ~2 ps regardless of doping.¹³ Similarly, in undoped dots, Sun *et al.* have found a capture time smaller that 2 ps,¹⁵ while Yuan *et al.* observed a capture time of about 10 ps.¹⁴

B. Carrier capture from the wetting layer into the dot

Following barrier-to-wetting layer carrier capture, the hole relaxes to the lowest-energy confined hole state h_N while the electron is captured from the bottom of the wetting layer to the highest-energy confined state [illustrated by P; Fig. 1(b)]. Sosnowski et al.¹⁶ found in time-resolved differential transmission experiments at low excitation in an (In,Ga)As/GaAs dot with two confined electron states that the electron capture time is 2.8 ps. On the other hand, a combined capture time has been derived from time-resolved photoluminescence (PL) experiments at high excitation by several groups. (These times are affected by the subsequent intradot carrier relaxation.) Siegert et al.¹³ have found a capture time of 4.9 ps in undoped dots, and 5.4 and 6.1 ps in *n*-doped and *p*-doped dots, respectively.¹⁷ Similarly, Yuan *et* al.¹⁴ found a capture time within 5 ps, while Sun et al. found a capture time of less than 2 ps.¹⁵



FIG. 1. Sketch of different dynamical process experienced by photocreated carriers in a self-assembled (In,Ga)As/GaAs quantum dot: (a) Barrier-to-wetting layer (WL) carrier capture, (b) carrier capture from the wetting layer into the dot, (c) carrier relaxation within the dot, and (d) thermal escape of carriers.

C. Relaxation of excited carriers within the dot

Following carrier capture from the wetting layer into the dot, carriers can experience different dynamical processes. These processes largely reflect the type of spacings that exist between various confined states. The (In, Ga)As/GaAs system has interesting properties in this respect. First, not only are these direct gap materials, but the competing bandstructure valleys (X,L) are rather far energetically from Γ [unlike InP or PbSe (Ref. 18)]; thus, these materials, especially InAs, are in fact strongly direct-gap systems. Second, the hole mass in InAs is much heavier than the electron mass; thus, confined hole states tend to be more densely spaced than electron states. Third, the electron states are arranged in S, P, D... "shells" and each shell shows intrashell level splittings, e.g., $\mathcal{E}(P_1) \neq \mathcal{E}(P_2)$ are split by 1–6 meV, while intershell splittings are larger, e.g., S-P spacing is 40-60 meV (Refs. 6-9, 11, and 19) (compared to \sim 300 meV in CdSe dots). Thus, the intrashell splitting is of the order of (small wave vector) acoustic phonon energies, whereas intershell spacing is larger than (small wave vector) longitudinal optical phonon energies. Therefore, intershell relaxation via single-phonon emission due to electronphonon coupling (within the Born-Oppenheimer adiabatic approximation) is expected to be ineffective^{20,21}—the phonon-bottleneck effect-because energy cannot be conserved in the intershell relaxation process. Finally, hole states do not form shells, with the exception of flat dots²² (height of ~ 20 Å), and the splitting between hole states is about 1-20 meV, thus comparable to acoustic phonon frequencies.

Given these general characteristics, the main electron- and hole-relaxation channels within the dot are:

(i) Hole thermalization. The hole relaxes to h_0 , most

likely via electron–acoustic-phonon emission. Such a hole relaxation has been found to occur within subpicosecond times.^{16,23} Moreover, Quochi and co-workers showed that the hole relaxation time depends strongly on temperature: 20 ps at 60 K and 0.8 ps at 300 K.²⁴ Note that in CdSe colloidal dots the existence of energy gaps of ~60 meV *within* the valence-band quasi-continuum was shown experimentally²⁵ and theoretically²⁶ to slow down the hole thermalization.

(ii) Intrashell electron relaxation (e.g., $P_2 \rightarrow P_1$; Fig. 1). The electron relaxes from $P_2 \rightarrow P_1$ (1–6 meV splitting) or between magnetic-field split states, via acoustic phonon emission. From optical pumb-probe measurements, Zibik *et al.* have recently deduced relaxation times of 15 and 35 ps for P_1 - P_2 splittings of 3.7 and 5.5 meV,¹⁰ respectively. A model calculation that adopts longitudinal acoustic phonon emission predicts, correspondingly, values of 8 and 34 ps.¹⁰

(iii) Inter-shell electron relaxation for sole carrier and for electron-hole pair (e.g., $P \rightarrow S$; Fig. 1) within the 40–60 meV separating the electronic shells. This relaxation is different if an electron-hole pair is present or just a sole electron (doped dot).

As expected from the phonon bottleneck effect, intershell relaxation in (In, Ga)As/GaAs dots has been observed to be slow by Urayama *et al.*²³ (relaxation time of \sim 750 ps) as well as Heitz et al.27 (7.7 ns). In contrast, time-resolved optical measurements have clearly demonstrated that this intershell decay is a *fast* process whether a hole is present or not. For instance, in experiments in which both an electron and hole are present, Müller et al. have found decay times of 4.7 ps at 5 K and 2.8–1.5 ps (depending on excitation power) at room-temperature in interband-pump-intrabandprobe experiments;¹⁹ Boogart *et al.* found 19 ps (low intensity) and 9 ps (high intensity) within 5 and 77 K, but 7 ps (high intensity) at room temperature, in time-resolved pumpprobe differential reflectance spectroscopy.²⁸ Sosnowski et al. found 5 ps at 10 K in pump-probe differential transmission experiments;¹⁶ De Giorgi et al. found 6.5 ps at 4 K (3.0 ps at high intensity) and 3.5 ps at room temperature in time-resolved PL upconversion experiments;²⁹ with the same experimental technique, applied to large (b=350 Å, h)=110 Å) and small (b=250 Å, h=30 Å) dots, Boggess *et al.* found, respectively, 1 and 7 ps below 100 K, and \sim 2.5 ps at 200 K and 6 ps at 150 K;³⁰ while Siegert *et al.* found that at 80 K the $D \rightarrow S$ decay time corresponds to 7, 3, and 2 ps for undoped, *n*-doped, and *p*-doped dots, respectively.¹³ On the other hand, when a sole electron is present and no hole, the intershell relaxation time slows down by a factor of about 2-10. For instance, in *n*-doped (In,Ga)As/GaAs quantum dots the low-temperature $P \rightarrow S$ relaxation time has been extracted from pump-probe infrared spectroscopy and is in the range of 20-65 ps in the experiments of Zibik et al.9 and 40-70 ps in the experiments of Sauvage *et al.*¹¹ In the latter, the room-temperature $P \rightarrow S$ relaxation is 37 ps for $\Delta(S-P)$ \simeq 54.5 meV. Note that in earlier pump-probe interband absorption experiments at high excitation, Sauvage et al. found a relaxation time of 3 ps at room temperature.³¹ The situation is similar in colloidal dots, such as CdSe, where the $P \rightarrow S$ intershell relaxation in the absence of a hole slows down to $\sim 10 \text{ ps}$,¹² relative to $\sim 1 \text{ ps}$ when an electron-hole pair is present.

Several relaxation mechanisms have been proposed as responsible for the fast intershell relaxation: multiphonon emission,³² Auger (carrier-carrier) scattering,^{33–36} and polaron relaxation.^{37–40} (We discuss the Auger and polaron models in Sec. III.)

D. Thermal escape of carriers from dot

On increasing temperature, the photoexcited electron and hole escape the confined states of the dot [Fig. 1(d)]. Thermal depopulation has been found to be significant at temperatures $T > 100 \text{ K}.^{29,41,42}$ However, Heitz and co-workers have found the onset to be 200 K.⁴³ In *n*-doped InAs/GaAs dots, Bras and co-workers showed that thermal depopulation becomes significant above 70 K.⁶

III. AUGER AND POLARON MECHANISMS FOR $P \rightarrow S$ INTERSHELL DECAY

A. Auger relaxation via electron-hole scattering

Figure 1(c) illustrates this process whereby the hot electron decays by scattering a low-lying photoexcited hole into deep hole states like h_k . Scattering takes place via the electron-hole Coulomb interaction; thus, this relaxation process does not take place in the absence of a photexcited hole. For the mechanism to be effective it requires energy conservation: The excess energy of the electron has to be elastically transferred to the hole [as sketched in Fig. 1, where $\mathcal{E}_{1}^{(e)}$ $-\mathcal{E}_{0}^{(e)} = \mathcal{E}_{0}^{(h)} - \mathcal{E}_{k}^{(h)}$]. On the other hand, electronic level broadening due to phonons effectively relaxes this stringent condition.¹⁶ In (In,Ga)As/GaAs self-assembled quantum dots, the $\mathcal{E}_{p}^{(e)} - \mathcal{E}_{S}^{(e)} \sim 50$ meV, whereas in CdSe colloidal dots $\mathcal{E}_{p}^{(e)} - \mathcal{E}_{S}^{(e)} \sim 300$ meV. In the latter case, the $P \rightarrow S$ decay via Auger process is highly effective.⁴⁴⁻⁴⁷ In fact, Hendry et al.48 have demonstrated the validity of the electronhole Auger mechanism for $P \rightarrow S$ relaxation in CdSe dots by measuring directly the hole thermalization time (Sec. II C) versus the electron excess energy. Moreover, in Ref. 47 Guyot-Sionnest and co-workers have shown that in CdSe dots the $P \rightarrow S$ relaxation of electrons is slowed down upon inducing hole trapping at the surface of the dots. This is strong evidence in favor of relaxation due to electron-hole Auger scattering. The effectiveness of the Auger mechanism for $P \rightarrow S$ relaxation in self-assembled dots has been previously addressed within model Hamiltonians only.^{34,35} Here it will be calculated by using a fully atomistic approach. When the hole is absent (due to its capture by a hole quencher or when only an electron is injected into the dot) the Auger mechanism is not possible. In CdSe colloidal dots, the alternative mechanism corresponds to the coupling of the electrons in the dot with virtual phonons of the environment.¹² In (In,Ga)As/GaAs self-assembled dots the polaron decay has been proposed instead.^{37,39,40}

B. Polaron decay for a single excited electron (no hole)

This mechanism has been invoked to explain the electron relaxation to state e_0 in the *absence* of a hole. The confined electron states are assumed to be strongly coupled

with the continuum of states arising from the phonon replicas of the localized states (e.g., S, P), thereby, forming stable polaron states. In turn, these polaron states relax when the phonon component of the polaron relaxes due to phonon anharmonicity.³⁷ Thus, assuming that the phonon component of the polaron originates from LO phonons, the phononbottleneck is circumvented by the emission of an LO and a TA phonon. This mechanism requires that the S-P energy difference be of the order of the zone-center optical phonon energy. In colloidal dots, $\mathcal{E}(P) - \mathcal{E}(S) \sim 200 - 500$ meV for electrons while $\hbar\omega_{LO} \sim 30$ meV; thus, the polaron decay mechanism is not possible. On the other hand, for holes in colloidal dots, $\mathcal{E}(P) - \mathcal{E}(S) \sim 10 - 30$ meV, which would make the polaron decay possible. In (In,Ga)As/GaAs selfassembled dots, $\mathcal{E}(P) - \mathcal{E}(S) \sim 50$ meV for electrons and ranges from 5–20 meV for holes while $\hbar\omega_{LO} \sim 30$ meV, thus making the polaron decay feasible.

In the case of the intershell $P \rightarrow S$ transition in (In,Ga) As/GaAs, the polaron state has been predicted to relax within a few picoseconds,³⁷ leaving the excited electron in the S state. This model explains the observed relaxation times in the absence of a hole (Sec. II C).⁴⁹ Further data that have been taken as evidence of the polaron model in (In,Ga)As/GaAs dots correspond to the anticrossings in the energies of allowed far-infrared transitions in magnetospectroscopy as the field is swept.⁵⁰ The magnitude of the anticrossings (\sim 3 meV) present in the spectra is consistent with those predicted by the polaron model.⁵⁰ We note that in low-symmetry dots, all states have the same a_1 symmetry even without phonon displacements and, therefore, they would anticross in the presence of a magnetic field. Whether the reason for lowering the symmetry to a_1 is phonon coupling or simply the correct atomistic dot symmetry of the nonvibrating dot remains to be determined.

IV. CALCULATION OF AUGER COOLING DUE TO ELECTRON-HOLE SCATTERING

We have calculated the Auger cooling lifetime of electrons in $In_{0.6}Ga_{0.4}As/GaAs$ quantum dots within a pseudopotential-based atomistic approach⁵¹ in order to establish if this mechanism leads to $P \rightarrow S$ decay times within magnitude needed to explain low-excitation experiments in which a photoexcited hole is present.

A. Method of calculation

We begin by calculating the single-particle ladder $\{e_0, e_1, e_2, ...\}$ and $\{h_0, h_1, h_2, ...\}$ of electron and hole states, respectively, of the (In, Ga)As/GaAs quantum dot. The wave function ψ_j and energy \mathcal{E}_j of these states are solutions of the atomistic single-particle Schrödinger equation

$$\left[-\frac{1}{2}\nabla^2 + V_{\rm SO} + \sum_{l,\alpha} v_{\alpha}(\mathbf{R} - \mathbf{R}_{l,\alpha})\right]\psi_j = \mathcal{E}_j\psi_j.$$
 (1)

Here, the actual potential of the solid (dot+GaAs barrier) is described by a superposition of (semiempirical) screened pseudopotentials v_{α} for atom of type α (In,Ga,As) with position $\mathbf{R}_{l,\alpha}$ within the dot or barrier, and a nonlocal pseudopotential V_{SO} that accounts for the spin-orbit interaction.⁵² To solve Eq. (1), we expand ψ_j in a linear combination of Bloch bands $u_{n,\mathbf{k}}^{(M)}(\mathbf{R})$ of material M (InAs, GaAs), with wave vector \mathbf{k} and band index n, subjected to strain $\tilde{\varepsilon}^{.53}$

$$\psi_j(\mathbf{R}) = \sum_M \sum_{n,\mathbf{k}} C_{n,\mathbf{k};M}^{(j)} u_{n,\mathbf{k};\varepsilon}^{(M)}(\mathbf{R}).$$
(2)

This expansion has a main advantage over a plane-wave expansion: The Bloch bands $u_{n,\mathbf{k};\varepsilon}^{(M)}(\mathbf{R})$ can be intuitively chosen, which reduces the computational demand significantly.⁵³ To calculate the electron Auger cooling lifetime $\tau(P \rightarrow S)$ due to electron-hole scattering at low temperatures, we proceed in two steps.

1. Calculation of Auger scattering rates for individulal electronhole configurations

We consider as initial electron-hole configurations $|e_ih_j\rangle$ those corresponding to the electron in the *P*-shell states $\{e_1, e_2\}$ and the hole in low-lying states h_j ; and as the final scattering states those that correspond to an electron occupying the *S*-shell state e_0 and a hole in a deep state h_k [Fig. 1(c)], i.e., $|e_0h_k\rangle$. Then, we calculate the net, characteristic Auger scattering rate of the transition $|e_i\rangle \rightarrow |e_0\rangle$ (i=1,2), with a hole in state h_i , by using Fermi's golden rule:

$$\frac{1}{\tau_{i_h}(e_i \to e_0)} = \frac{2\pi}{\hbar} \sum_k |J_{ij;0k}^{(eh)}|^2 \delta[E(i;j) - E(0;k)].$$
(3)

Here, $E(i_e; i_h)$ and E(0; k) correspond to the many-particle energy of the initial and final state, respectively, calculated at the single-configuration level of approximation.⁵⁴ The electron-hole Coulomb scattering matrix elements $J_{i_e i_h;0k}^{(eh)}$ are given by

$$J_{ij;0k}^{(eh)} = \int \int d\mathbf{R} d\mathbf{R}' \frac{\left[\psi_j^{(h)}(\mathbf{R})\right]^* \left[\psi_i^{(e)}(\mathbf{R}')\right]^* \psi_0^{(e)}(\mathbf{R}') \psi_k^{(h)}(\mathbf{R})}{\epsilon(\mathbf{R},\mathbf{R}') |\mathbf{R}-\mathbf{R}'|},$$
(4)

where $\epsilon(\mathbf{R}, \mathbf{R}')$ is the microscopic dielectric function derived by Resta.⁵⁵ Note that in the actual computations, we introduce a phenomenological broadening Γ of the final states that allow us to replace $\delta(x)$ in Eq. (3) with a Gaussian function $(\Gamma\sqrt{2\pi})^{-1} \exp(-x^2/2\Gamma^2)$. One should understand Γ as a phenomenological way to account for the phononinduced (e.g., phonon broadening) finite lifetime τ_h of the excited single-particle hole states: $\Gamma \sim 2\pi \hbar/\tau_h$. Considering that experimentally the relaxation of a hole in the wetting layer to h_0 takes about 0.6 ps,¹⁶ we estimate a lower bound for Γ of 10 meV. The phenomenological parameter Γ has been used in previous calculations (Refs. 34 and 44).

Figure 2 shows the characteristic Auger relaxation lifetime $\tau_{h_0}(e_1 \rightarrow e_0)$ calculated for two values of Γ in two lensshaped In_{0.6}Ga_{0.4}As/GaAs quantum dots—D1 and D2—of size (252 Å, 35 Å). These dots differ only in the random alloy disorder realization. For a phenomenological broadening, Γ =5 meV, $\tau_{D1}(P \rightarrow S) \sim 20$ ps, and $\tau_{D_2}(P \rightarrow S) \sim 35$ ps. The strong difference shows that $\tau_{h_0}(e_1 \rightarrow e_0)$ depends



FIG. 2. Electronic Auger cooling characteristic lifetime $\tau_{h_0}(e_1 \rightarrow e_0)$ calculated with two phenomenological broadenings— Γ =5 and 10 meV—for dots of the same size (b,h)=(252 Å, 35 Å). Dots D1 (open squares) and D2 (solid circles) correspond to different random alloy disorder realizations.

strongly on the energy structure of the final states. For a more plausible value of the broadening, $\Gamma = 10 \text{ meV}$, $\tau_{h_0}(e_1 \rightarrow e_0) \sim 5 \text{ ps}$ for both dots.⁵⁶ In addition, we find that $\tau_{h_0}(e_1 \rightarrow e_0) \approx \tau_{h_0}(e_2 \rightarrow e_0)$; D2 presents a difference of 1.5 ps among these lifetimes. We also show, for a comparison, $\tau_{h_0}(e_1 \rightarrow e_0)$ for dot D1 under a hydrostatic pressure of 2.4 GPa. Because this pressure does not significantly change the intraband energy structure of the confined states but primarily increases the localization of their wave functions,⁵⁷ the characteristic relaxation lifetime is smaller than at ambient pressure.

2. Solution of rate equations describing $P \rightarrow S$ electron relaxation

Once we have calculated the characteristic times $\tau_{i_h}(e_i \rightarrow e_0)$, we note that (i) at low temperatures $(k_B T \ll \mathcal{E}_1^{(h)})$ $-\mathcal{E}_0^{(h)}$) there are two relevant initial electron-hole configurations $|1\rangle = |e_1 h_0\rangle$ and $|2\rangle = |e_2 h_0\rangle$ that decay to a single scattering configuration $|s\rangle = |e_0 h_k\rangle$. (ii) In addition, due to the $P \rightarrow P$ intrashell relaxation, configuration $|2\rangle$ decays to $|1\rangle$ with a relaxation time $\tau (e_2 \rightarrow e_1) = \tau_{21}$ between 15 and 35 ps.⁹ Thus, we find the time-dependent occupation of n_1 , n_2 , and n_S by solving numerically the following set of rate equations:

$$\frac{dn_1}{dt} = -\left[\gamma^{(+)} + (\tau_{h_0}(e_1 \to e_0))^{-1}\right]n_1 + \gamma^{(-)}n_2$$

$$\frac{dn_2}{dt} = -\left[\gamma^{(-)} + \left[\tau_{h_0}(e_2 \to e_0)\right]^{-1}\right]n_2 + \gamma^{(+)}n_1$$

$$\frac{dn_s}{dt} = \left[\tau_{h_0}(e_1 \to e_0)\right]^{-1}n_1 + \left[\tau_{h_0}(e_2 \to e_0)\right]^{-1}n_2$$
(5)



FIG. 3. (Color online) Auger cooling lifetime $\tau(P \rightarrow S)$ vs temperature for seven lens-shaped quantum dots of different sizes. The pair (b,h) indicates the base diameter and height of the dots. Data from Refs. 13, 16, 19, and 41 are also shown.

with initial conditions taken to be $n_1(0)=n_2(0)=1/2$ and $n_s(0)=0$. These initial conditions reflect the fact that the electrons captured in the dot have the same probability to decay to P_1 or P_2 (see Sec. II C).

Here, $\gamma^{(+)}$ and $\gamma^{(-)}$ are the rates of transitions $n_1 \rightarrow n_2$ and $n_2 \rightarrow n_1$, respectively, with

$$\gamma^{(+)} = \frac{1}{\tau_{21}} \left[\exp\left(\frac{\Delta E}{k_B T}\right) - 1 \right]^{-1} \tag{6}$$

and

$$\gamma^{(-)} = \frac{1}{\tau_{21}} \left[1 + \left(\exp\left(\frac{\Delta E}{k_B T}\right) - 1 \right)^{-1} \right],$$
 (7)

where $\Delta E = E(2;0) - E(1;0)$. Finally, we extract electron Auger relaxation $\tau(P \rightarrow S)$ by fitting the time-dependence of the occupation probability n_s to the expression $1 - \exp[-t/\tau(P \rightarrow S)]$. For the characteristic times $\tau_{h_0}(e_1 \rightarrow e_0)$ and $\tau_{h_0}(e_2 \rightarrow e_0)$ calculated with $\Gamma = 10$ meV, and $\tau_{21} = 15$ ps, the fit is excellent.

B. Predicted $\tau(P \rightarrow S)$ and comparison to data

Figure 3 shows $\tau(P \rightarrow S)$ versus temperature for lensshaped dots of different sizes [(base, height)]. In these calculations the broadening $\Gamma = 10$ meV is larger than the average energy spacing of the relevant final states and τ_{21} =15 ps. Two features are prominent. (i) $\tau(P \rightarrow S)$ decreases with both increasing height at a fixed base and increasing base at a fixed height. (ii) The Auger cooling lifetime of (150 Å, 75 Å) is similar to that of dots with size (252 Å, 35 Å) due to their similar single-configuration exciton gap (see below). *Comparison to data*: In Fig. 3, we also show data extracted from differential transmission spectroscopy



FIG. 4. Calculated Auger-cooling lifetime $\tau(P \rightarrow S)$ at T = 10 K vs the single-configuration exciton gap for several lens-shaped quantum dots.

experiments⁴¹ and time-resolved photoluminescence experiments^{13,16,19} in (In,Ga)As/GaAs dots appear as squares and diamonds. A comparison to our calculated values shows the following. (i) We find excellent agreement between our calculated $\tau(P \rightarrow S)$ for the (252 Å, 35 Å) dot D1 and the value of 5.2 ps found by Sosnowski and co-workers in differential transmission spectroscopy in (In,Ga)As/GaAs dots with a gap of 1.265 eV.¹⁶ Dot D2 and the dot with size (150 Å, 75 Å) also compare well to experiment. (ii) The value of 2.5 ps for $\tau(P \rightarrow S)$ at 5 K (Fig. 3) in InAs/GaAs dots with energy gap of 1.08 eV that has been derived by Müller et al.¹⁹ from pump-probe intraband spectroscopy is in satisfactory agreement with our predicted values for (252 Å, 50 Å), (252 Å, 65 Å), and (200 Å, 75 Å) dots. (iii) Our results for the flat dot (h=20 and 35 Å) compare well to the $\tau(P \rightarrow S)$ data of Norris *et al.*⁴¹ at low temperatures. The data of Siegert et al.¹³ below 100 K is comparable to our low-temperature predicted values. Note that Norris et al. have found that above 100 K, thermal escape of carriers [Fig. 1(d)] is important, which explains the large abrupt reduction of the Auger decay time seen in the data.⁴¹

C. Trend of $\tau(P \rightarrow S)$ with exciton gap

Figure 4(a) shows the calculated low-temperature (10 K) Auger relaxation lifetime as a function of the dot exciton gap for several In_{0.6}Ga_{0.4}As/GaAs quantum dots.⁵⁸ Two important features emerge: (i) We find that $\tau(P \rightarrow S)$ ranges from 1–7 ps and decreases with the gap of the dots. As the *S*-*P* splittings of the lens-shaped dots is nearly the same, we attribute the reduction of $\tau(P \rightarrow S)$ to the *increase* of the joint density of states

$$g[E(i_e, i_h)] = \sum_k \delta[E(i_e; i_h) - E(0; k)]$$
(8)

that takes place as the gap of the dot *decreases*, due to the increase in the density of single-particle hole states.

D. Comparison to other calculations for (In,Ga)As/GaAs dots

We have compared our results to two model calculations: (i) The eight-band $\mathbf{k} \cdot \mathbf{p}$ calculation of Jiang and Singh³⁴ and (ii) the parabolic, single-band effective-mass calculation of Ferreira and Bastard.³⁵ Our results agree well with the calculation in (i). Namely, Jiang and Singh show an increase of the characteristic Auger cooling lifetime with decreasing Γ . In addition, the results of Jiang and Sing compare satisfactorily (within a factor of two) with the value of $\tau(P \rightarrow S)$ observed by Sosnowsky et al.¹⁶ A direct comparison with (ii) is not fully applicable since Ferreira and Bastard³⁵ consider different initial states than those considered here (Sec. IV A). In particular, the starting electron-hole pair states correspond, in our language, to $|e_1h_1\rangle$ and $|e_1h_2\rangle$. However, it is interesting to see that Ferreira and Bastard find that the Auger-cooling lifetime is within 0.1 and 6 ps. Moreover, depending on the choice of initial e-h states, this lifetime either increases as gap decreases (in contrast to our predictions; Fig. 4) or vice versa.

E. Digression: Comparison with calculations and data for CdSe colloidal dots

Wang *et al.*⁴⁴ have calculated $\tau(P \rightarrow S)$ for CdSe colloidal dots using the same methodology as in this paperpseudopotential-based atomistic approach-finding, respectively, relaxation times of 0.6 and 0.2 ps for dots with radii of 29 and 38 Å. These results show that, in contrast to In_{0.6}Ga_{0.4}As/GaAs dots, $\tau(P \rightarrow S)$ increases with decreasing the dot gap. Moreover, for In_{0.6}Ga_{0.4}As/GaAs dots, we predict $\tau(P \rightarrow S)$ s that are about a factor of 10 slower. The $\mathbf{k} \cdot \mathbf{p}$ -based calculation of Efros and co-workers⁵⁹ predicts Auger decay lifetimes in CdSe colloidal dots of ~ 2 ps almost independently of dot size for radii between 20 and 40 Å. Although the magnitude of $\tau(P \rightarrow S)$ s that we find in (In,Ga)As/GaAs dots is comparable to that of Efros and co-workers, the gap dependence is strikingly different. On the other hand, bleaching experiments in CdSe colloidal quantum dots show that the Auger cooling lifetime of electrons is below a picosecond and *decreases* as the exciton gap increases.⁴⁵ [Note that the calculations of Wang et al.⁴⁴ reproduce these experimental findings.] We predict that $\tau(P)$ \rightarrow S) \sim 1–7 ps in (In,Ga)As/GaAs self-assembled quantum dots and shows the opposite gap dependence (Fig. 4). The gap dependence of $\tau(P \rightarrow S)$ in both colloidal and selfassembled dots is dictated by the gap (size) dependence of (i) the joint density of states [Eq. (8)] and (ii) the magnitude of the Coulomb scattering integrals [Eq. (4)]. Although in (In,Ga)As/GaAs self-assembled dots the changes with size in the joint density of states prevails, in CdSe colloidal dots the changes of the Coulomb integrals dictates the gap dependence of $\tau(P \rightarrow S)$.

V. SUMMARY

We have discussed several dynamical processes that photoexcited electrons and holes undergo in (In,Ga)As/GaAs self-assembled quantum dots and calculated the intershell P-to-S electron decay lifetime due to Auger electron-hole scattering in these dots. When only an electron (or only a hole) is present due to doping and this sole carrier is excited by a photon, its decay must involve a non-Auger mechanism (perhaps polaron decay). But when both an electron and hole are present we show that this Auger cooling takes place within picoseconds, which makes it an efficient intershell relaxation process compared to radiative recombination (~ 1 ns). In addition, we predict that the lifetime $\tau(P \rightarrow S)$ increases with the exciton gap. Our pseudopotential-based calculations confirm earlier predictions of simplified, model calculations. The values we find for $\tau(P \rightarrow S)$ compare well to recent data in the presence of photoexcited holes. This finding, complemented with our review of the data in the literature, allows us to conclude that in the presence of a photoexcited hole there is no need to invoke the alternative polaron-decay mechanism for intershell electron relaxation. This conclusion could be tested in (In,Ga)As/GaAs dots by measuring the rate of hole thermalization versus the electron excess energy, or by measuring the electron relaxation rate after modifying the surface of the dot so as to cause hole trapping. Finally, a consistent picture of electron relaxation within quantum dots appears to demand two relaxation mechanisms: electron-hole Auger scattering and polaron decay.

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